

Optically Active Silylanions. Evidence for the Formation of Analogues of Silyl Grignard Reagents

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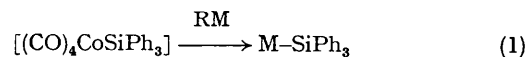
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Summary The preparation and reactions of an analogue of R_3SiMgX are reported; its reactions proceed with 55% retention of configuration and those of the analogous R_3SiLi 70%.

SILYL anions offer a versatile synthetic route to organosilanes and have been widely studied¹ *e.g.*, the 'S-system' of Calas and Dunoguès² offers a large variety of synthetic possibilities. We describe here a possible new route to silyl anions, and particularly to R_3SiMgX . The formation of

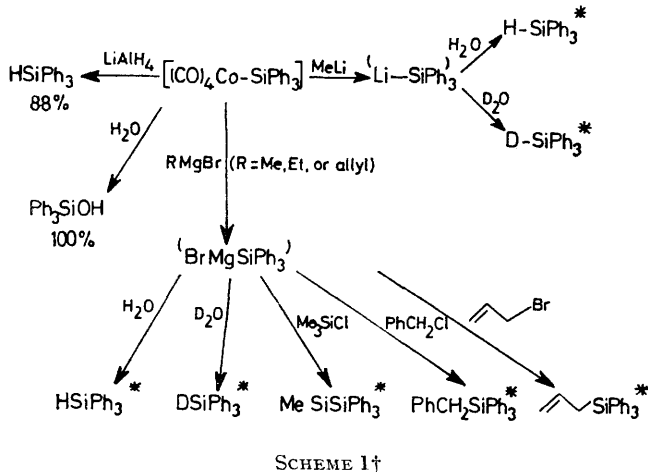
this species has never been established but was reasonably invoked by West³ and Gilman⁴ and their co-workers.

Treatment of $[(CO)_4CoSiPh_3]^5$ with a tenfold excess of a Grignard or alkyl-lithium reagent led to the formation of the corresponding anionic reagent (reaction 1). The reactions



M = MgBr, R = Me, Et, or allyl; M = Li, R = Me

of these derivatives are shown in Scheme 1. Hydrolysis with D_2O yields only the deuteriated silane, showing that the silane is formed from an anionic species, since hydrolysis of the cobalt-silicon complex gives the silanol quantitatively. The reactions of the alkyl halides gave further proof that the coupling reactions did proceed through a silyl anion, since they are unreactive towards Co-Si bonds.



Treatment of the optically active compound $[(+)\text{-}(\text{CO})_4\text{-CoSiMePh}(\alpha\text{-Np})]$, $[\alpha]_D^{25} + 2.7^\circ$ with a Grignard reagent yielded a silyl Grignard reagent of low optical activity (Scheme 2). Treatment with MeLi gave, after hydrolysis, a silane with 70% retention of configuration. These results should be compared with those obtained by Sommer and Mason⁷ for the preparation of an optically active silyl-lithium.

Surprisingly, treatment of $[(\text{CO})_4\text{CoGePh}_3]$,⁸ m.p. 158—160 °C, with MeMgBr led to substitution on Ge, while allylmagnesium bromide led to the germyl Grignard reagent (Scheme 3).

† Reactions marked with an asterisk (*) in Schemes 1 and 3 take place in ca. 40% yield. We presume that this corresponds to the yield of the silyl or germyl anion formed. After hydrolysis ca. 40% yields of the silanol or germanol byproduct are formed. Some tar is formed in all cases.

¹ P. Wittenberg and H. Gilman, *Quart. Rev.*, 1959, **13**, 116; D. D. Davis and C. E. Gray, *Organometallic Chem. Rev. (A)*, 1970, **6**, 283, and references therein.

² R. Calas and J. Dunoguès, *J. Organometallic Chem.*, in the press, and references therein.

³ T. G. Selin and R. West, *Tetrahedron*, 1959, **5**, 97.

⁴ M. W. George, D. J. Peterson, and H. Gilman, *J. Amer. Chem. Soc.*, 1960, **82**, 403.

⁵ A. J. Chalk and J. F. Harrod, *J. Amer. Chem. Soc.*, 1967, **89**, 1640.

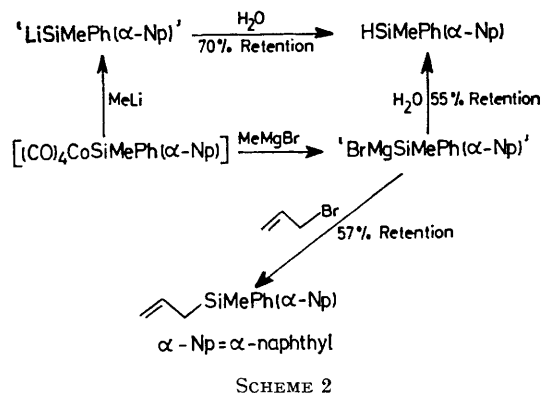
⁶ L. H. Sommer, J. E. Lyons, and H. Fujimoto, *J. Amer. Chem. Soc.*, 1969, **91**, 7051.

⁷ L. H. Sommer and R. Mason, *J. Amer. Chem. Soc.*, 1965, **87**, 1619.

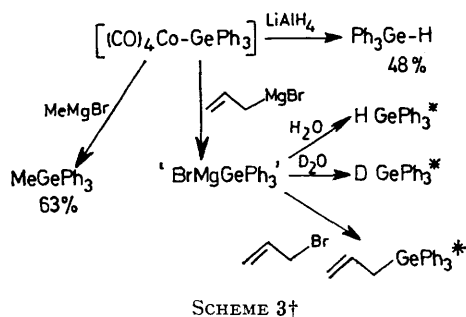
⁸ D. J. Patmore and W. A. G. Graham, *Inorg. Chem.*, 1967, **8**, 981.

⁹ E. Colomer and R. Corriu, to be published.

¹⁰ D. J. Darensbourg and M. Y. Darensbourg, *Inorg. Chem.*, 1970, **9**, 1691.



The behaviour of these complexes is surprising since we had expected nucleophilic attack on silicon or germanium to occur. In fact treatment of both types of compounds with LiAlH_4 led to formation of the corresponding Si-H or Ge-H bond. The reaction takes place⁹ with inversion of configuration in the case of the optically active cobalt-silicon compound.



The magnesium or lithium alkyl probably attacks the carbonyl ligands,¹⁰ the silicon unit being displaced as a silyl anion.

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